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Compact Thermal-Diffusivity-Based Temperature Sensors in 40-nm CMOS for SoC Thermal Monitoring

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Abstract— An array of temperature sensors based on the thermal diffusivity (TD) of bulk silicon has been realized in a standard 40-nm CMOS process. In each TD sensor, a highly-digital VCO-based $\Sigma\Lambda$ ADC digitizes the temperature-dependent phase-shift of an electro-thermal filter (ETF). A phase calibration scheme is used to cancel the ADC's phase offset. Two types of ETF were realized, one optimized for accuracy and one optimized for resolution. Sensors based on the accuracy-optimized ETF achieved a resolution of 0.36 °C (rms) at 1 kSa/s, and inaccuracies of ± 1.4 °C (3 σ , uncalibrated) and ± 0.75 °C (3 σ , room-temperature calibrated) from -40 to 125 °C. Sensors based on the resolution-optimized ETFs achieved an improved resolution of 0.21 °C (rms), and inaccuracies of ± 2.3 °C (3 σ , uncalibrated) and ± 1.05 °C (3 σ , room-temperature calibrated). The sensors draw 2.8 mA from supply voltages as low as 0.9 V, and occupy only 1650 μ m², making them some of the smallest smart temperature sensors reported to date, and well suited for thermal monitoring applications in systems-on-chip (SoC).

I. INTRODUCTION

Today, microprocessors and other systems-on-chip (SoCs) employ billions of transistors that can switch at GHz rates. As a result, they can get hot enough to degrade their performance and even cause permanent damage. To avoid this, thermal management algorithms, driven by information from on-chip temperature sensors, slow them down or even shut them off when temperatures near reliability limits. To account for sensor errors, however, such algorithms must incorporate an appropriate safety margin. Given that the thermal resistance of a well-designed heat sink may be as low as 0.5 °C/W, a 5-°C margin corresponds to 10 W of unused power [1]. Since a typical microprocessor dissipates less than 100 W, this represents a significant loss of computing performance, and thus motivates the design of accurate temperature sensors. In multi-core microprocessors, substantial thermal gradients and hot spots may occur, whose location is a dynamic function of workload. Thus, multiple on-chip temperature sensors are required, both to ensure reliability and to optimally spread the workload over different cores [2].

Since the location of hot spots cannot be easily predicted at design time, on-chip sensors must be small enough to be deployed in large numbers (up to 44 in modern microprocessors [3]), and for their position in the layout to be flexibly moved, even at a late stage of the development [2]. Accuracy requirements must be satisfied while minimizing the calibration effort, which could otherwise significantly increase manufacturing costs, especially when tens of sensors per chip are involved. The greatest accuracy is required around the reliability limit, with typical specifications being ± 1 °C at 70 °C, and only ± 3 °C at 50 °C [2]. In addition, to properly detect thermal transients with slopes as high as 0.5 °C/ms [2], sensor resolution must be significantly less than 0.5 °C, even with measurement times as short as 1 ms.

Most on-chip CMOS temperature sensors are currently based on parasitic PNPs thanks to their relatively simple design and good energy efficiency. When implemented in nanometer CMOS, however, it has been shown that their inaccuracy is limited to only a few degrees Celsius, even after trimming [2,4,5]. Parasitic NPNs achieve better performance [6][28], but are not available in baseline CMOS processes. Moreover, the base-emitter voltages of BJTs is about 0.7 V at room temperature, which makes it quite challenging to operate them from today's 1-V supplies. Other types of temperature sensors, e.g. based on resistors [7], or MOS transistors [8,9], also exhibit poor inaccuracy when implemented in nanometer CMOS, and so must be combined with expensive multi-point temperature calibration.

As an alternative, the thermal diffusivity (TD) of bulk silicon can be used as a measure of temperature. This is strongly temperature dependent (approximately proportional to $T^{1.8}$) and well defined for the highly pure silicon used in ICs [10]. A TD-based temperature sensor (TD sensor) operates by measuring the time that it takes for heat pulses from a heater, usually a diffusion resistor, to diffuse through the substrate to a relative temperature sensor, usually a thermopile. This diffusion process can be modeled as an electro-thermal low-pass filter, whose delay is in the order of a few micro-seconds for heater/thermopile spacings of a few micrometers. The corresponding phase shift is approximately proportional to absolute temperature ($\sim T^{0.9}$) [10].

The accuracy of an electrothermal filter (ETF) is mainly limited by variations in the spacing between the heater and the thermopile, which, in turn, is determined by the lithographic accuracy of the process used. Thus, the accuracy of TD sensors actually improves with technology scaling, as does the timing accuracy of their readout circuitry [11]. Moreover, since the required heat pulses can be generated from any supply voltage, TD sensors can be easily ported to newer technologies with lower supply voltages.

It has been shown that TD sensors can achieve untrimmed inaccuracy below 0.2 °C in 0.18µm CMOS [11]. However, the reported smart sensor was too large (0.18 mm²) and too slow (1 Sa/s) for thermal monitoring applications. By employing more compact electronics, much smaller smart TD sensors with areas of $8000~\mu m^2$ [12], and even $2800~\mu m^2$ [13], have been reported. However, these sensors were also implemented in a relatively mature 0.16- μm CMOS process.

This work presents the first TD sensor realized in nanometer (40 nm) CMOS. It demonstrates that the performance of TD sensors indeed continues to improve with scaling. Without temperature calibration, the sensor achieves $\pm 1.4^{\circ}$ C (3 σ) inaccuracy from -40 $^{\circ}$ C to 125 $^{\circ}$ C, which is 5x better than previous (non-TD) sensors intended for thermal monitoring [4,14-16]. This improves to ± 0.75 $^{\circ}$ C (3 σ) after a single-temperature calibration, a level of accuracy that, for non-TD sensors, requires two-temperature calibration [4,14,15]. Furthermore, it operates from a 0.9-V supply, and occupies only 1650 μ m², making it one of the smallest smart temperature sensors reported to date.

This paper begins with a description of the ETF design in section II and continues with the system level design in section III. The circuit implementation is detailed in section IV. Experimental results are shown in section V and conclusions are drawn in section VI.

II. ELECTRO-THERMAL FILTER DESIGN

The simplified layout of an ETF realized in a standard 40-nm CMOS process is shown in Fig. 1. The heater is a diffusion resistor, while the relative temperature sensor is a thermopile, i.e. a series connection of p+ silicon/Aluminum thermocouples. The heater is driven by a square wave at a constant frequency, so that the ETF's temperature-dependent delay manifests itself as a phase-shift in the thermopile's output voltage. The whole structure is placed in an n-well to shield it from electrical interference via the substrate. The effect of thermal interference via the substrate (e.g. due to other on chip circuitry) is not a concern, since this will be strongly low-pass filtered in the thermal domain [16].

In Fig. 1, the hot junction of each thermocouple, i.e. the p+/Al contact closest to the heater, is located at a distance *s* from the ETF's center, while the cold junctions are further away. Since each thermocouple produces a voltage proportional to the temperature difference between its hot and cold junctions, the ETF's output signal is larger for a shorter *s* and for longer thermocouple arms. However, reducing *s* means a larger sensitivity to lithographic errors, thus resulting in lower accuracy, while longer thermocouple arms have higher resistance, thus causing higher thermal noise.

Previous ETFs were optimized for accuracy at the expense of signal-to-noise ratio (SNR), which meant that their heater/thermopile spacing was relatively large ($s = 24 \mu m$). As a result, their readout bandwidth had to be less than 1 Hz to achieve reasonable resolution [17]. In this work, we leverage the improved lithographic accuracy of nanometer CMOS to implement ETFs with much smaller heater/thermopile spacing in order to improve SNR without significantly degrading accuracy. Moreover, an octagonal layout is used that minimizes thermopile resistance, and hence thermal noise, by maximizing the thermopile width. In this work, two ETFs were realized, with $s = 3.3 \mu m$ and $2 \mu m$, respectively, in order to explore the influence of s on ETF performance. Both ETFs occupy an area of 240 μm^2 and dissipate an average power of 2.1 mW from a 1.05-V supply.

For compatibility with previous work [12], the ETF drive frequency (F_{DRIVE}) is set at 1.17 MHz. From -40 to 125 °C, the phase shifts of the $s=3.3~\mu m$ and 2 μm ETFs are then expected to range from 35° to 60°, and from 25° to 45°, respectively. Based on thermal modeling, the corresponding output levels are expected to be 1.3 mVpp and 2.4 mVpp, respectively, for a heater power dissipation of 1mW [18]. Combined with the parasitic capacitance of the thermopiles, the thermopile's resistance R_{TP} , about 8 k Ω and 12 k Ω for the 3.3- μ m and 2- μ m ETFs, respectively, causes an additional phase shift of 0.4° and 0.6°. The spread on this RC

phase shift (about 30% over corners) will give rise to an equivalent temperature-sensing spread of less than 0.9 °C.

III. SYSTEM LEVEL DESIGN

The target sampling rate of 1 kSa/s and the small area requirement pose significant challenges on the design of the readout architecture. Fundamentally, an ETF's temperature information is contained in the phase delay of a small (~mV amplitude) signal, and so a sensitive and high-resolution phase-domain ADC is necessary. As shown in previous work [11,17], the phase-domain $\Sigma\Delta$ modulator (PD $\Sigma\Delta$ M) is a good candidate for this purpose. A PD $\Sigma\Delta$ M is a $\Sigma\Delta$ modulator with a feedback path in the phase domain. The required phase-domain summation node can be realized by a chopper demodulator, which demodulates the phase of the ETF signal (at a frequency F_{DRIVE}) by multiplying it with a square-wave at F_{DRIVE}, but with a known (reference) phase shift [17]. A PD $\Sigma\Delta$ M thus incorporates a synchronous phase detector and as such is only sensitive to interferers at frequencies very close to the drive frequency F_{DRIVE}. In an SoC, the presence of such interferers can readily be avoided by proper frequency planning.

Fig. 2 shows the block diagram of a first-order PDΣ Δ M. A gm-stage converts the ETF's output voltage (at frequency F_{DRIVE}) into current, whose phase shift (Φ_{ETF} , measured with respect to the phase of the signal driving the ETF's heater) is detected by a chopper demodulator driven by F_{DEM} . The phase-dependent DC current is then integrated on a capacitor and applied to a latched comparator, whose bitstream output (BS) switches F_{DEM} between outputs of a phase DAC (Φ_{DAC}) in a $\Sigma\Delta$ manner. For a single-bit modulator, Φ_{DAC} switches between the two phase references, Φ 0 and Φ 1. F_{DRIVE} and phase DAC outputs can be generated by a digital block, which is driven by an accurate high frequency clock (F_{SYNC}) [12]. However, such $PD\Sigma\Delta$ Ms require large integration capacitors and high-gain amplifiers [12], which in turn occupy significant area. Moreover, because of the need for high-gain amplifiers, this architecture does not scale well with technology [19].

A more digital-friendly architecture was proposed in [20] and is shown in Fig. 3. In such VCO-based PD $\Sigma\Delta M$, the combination of a voltage-controlled oscillator (VCO) and an up/down counter replaces the gm-stage, the chopper and the integration capacitor. Here, the ETF output signal V_{ETF} at frequency F_{DRIVE} and phase shift Φ_{ETF} modulates the VCO's output frequency (Fvco). An all-digital $\Delta\Sigma$ modulator then synchronously demodulates the VCO's output and digitizes the ETF's phase shift Φ_{ETF} . The functions of demodulation and integration are realized by the up/down counter, whose M most-significant bits (MSB) of its output word constitute the output bitstream. Such bitstream drives the phase DAC, which applies a digitally-delayed feedback signal (F_{DEM}) to the counter's up/down input. To improve accuracy, the modulator is usually operated as an incremental converter, where the counter is reset before each conversion [21]. The decimation filter can then be a simple counter (sinc filter) [20]. In contrast to previous work, a multi-bit DAC (M = 3) is chosen in this work, a choice which reduces both quantization noise and the inherent cosine non-linearity of synchronous phase demodulation [11] to negligible levels (± 0.04 °C). This avoids the complexity of a two-step conversion with single-bit incremental converters [12], without compromising performance.

However, a disadvantage of the proposed architecture is that the finite bandwidth of the VCO in Fig. 3 results in additional phase shift, which cannot be distinguished from Φ_{ETF} . In fact, while the gm-stage in Fig. 2 can be implemented by a fast differential pair immediately followed by a demodulating analog chopper [17], the VCO in Fig. 3 requires both a low-noise front-end and a cascaded oscillator element, and thus is inherently slower. In this work, the VCO's phase error is mitigated by a phase-calibration scheme in which the entire VCO-based PD $\Sigma\Delta M$ is driven by a reference square-wave (V_{CAL}) with a known phase shift (Φ_{CAL}). The additional phase error introduced by the readout can thus be determined and then subtracted from the results of subsequent conversions.

Fig. 4 shows the block diagram of a VCO-based PD $\Sigma\Delta M$ with phase calibration. Here, the VCO front-end is implemented as a gm stage followed by a current-controlled oscillator (CCO). The gm-stage isolates the weak ~mV_{pp} ETF signal from the CCO to prevent kick-back and also acts as a low-noise amplifier. The CCO drives an 8-bit up-down counter, whose 3 MSBs are latched by D flip-flops to realize the quantizer of a 3-bit $\Sigma\Delta$ modulator. The 3-bit unary phase DAC consists of a 3-bit multiplexer selecting the outputs of an 8-element delay line that shifts an input signal (F_{DL}), where $\angle F_{DL} = \angle F_{DRIVE} + 90^{\circ}$. The reference delay signal (F_{SYNC}) is an external 75-MHz clock, while F_{DRIVE} = 1.17 MHz. This results in a phase DAC LSB of 5.625°, but in order to cover a large range, the DAC LSB was chosen to be 11.25° in practice via dividing F_{SYNC} by 2. Therefore, the DAC spans from 101.25° to 180°. In order to minimize any circuit related delay, and hence any additional phase error in F_{DRIVE} and F_{DEM}, both clock signals are synchronized by F_{SYNC} before being delivered to the heater switches or to the up/down counter. Unlike prior work employing analog choppers [12], low-frequency chopping is not necessary to eliminate the residual offset due to chopper non-idealities because the up/down counter behaves like a near-ideal digital chopper. This further simplifies the drive logic, thus saving additional area.

The phase-calibration reference signal is generated by injecting a reference current from a current source (I_{CAL}) into the thermopile's resistances R_{TP} . The reference phase for phase calibration was chosen equal to 22.5°, a phase which requires only two flip-flops to generate.

The total budget for thermal noise (resolution), electrical phase delay (accuracy) and power of the proposed TD sensor is shown in Table I. The gm stage is optimized for low-power consumption and low area, thus leading to a gm-stage design that contributes ~30% of the total thermal noise and about half of the phase delay budgets.

In addition to thermal noise, the PD $\Sigma\Delta M$'s resolution is also affected by the quantization noise imposed by the CCO and counter combination. This occurs because the counter only

recognizes the rising edges of F_{VCO} , effectively quantizing the time-domain information coming from the CCO. In most amplitude-domain VCO-based ADCs, the VCO is cascaded to a fully-analog loop filter, thus providing high-pass shaping of this noise and effectively removing it from the band of interest [22]. Unfortunately, this is not the case for a phase-domain modulator. Indeed, CppSim [23] simulations of the PD $\Sigma\Delta M$ shown in Fig. 4 reveal that this quantization noise manifests itself as an input-referred white noise source. Nevertheless, simulations also confirm intuition in showing that such time-domain quantization noise is lower for a higher F_{VCO} frequency. For the proposed design, the nominal VCO frequency (F_{NOM}) is 630 MHz, while the voltage-to-frequency gain of the VCO (K_{VCO}) is 200 MHz/mV. With these values, simulations show that the additional quantization noise due to VCO is about 25 m° in a 500-Hz bandwidth, which translates into a temperature-sensing resolution of 0.16 °C.

IV. CIRCUIT DESCRIPTION

Fig. 5 shows the circuit level implementation of the gm-stage that supplies the CCO. The CCO can be modeled as a non-linear impedance r_{CCO} sinking a current I_{CCO} . For maximum efficiency and driving capability, $r_{CCO} \ll r_0$, where r_0 is the output impedance of the gm stage. Although r_{CCO} depends on the CCO architecture, it is typically in the order of tens of $k\Omega$'s. Therefore, the gm stage requires a high output impedance, as well as a high transconductance (gm) to meet the noise requirements shown in Table I. Moreover, it needs to work a supply voltage below 1 V to demonstrate compliance with current and future supply voltages for nanometer CMOS (1.1 V for 40-nm CMOS). In 40-nm CMOS technology, these three requirements necessitate the use of a two-stage amplifier architecture. A two-stage design also uses less transistors (8) than a folded-cascode (11) amplifier [17], and thus occupies less area. Although a two-stage amplifier may have larger delay than a single-stage amplifier, this can be compensated by the phase calibration.

The first stage (M1-4) is optimized for minimal thermal noise, and phase shift at F_{DRIVE} and has a gain of 25 dB and a bandwidth of 300 MHz. Its 10-nV/VHz noise density (see Table I) is mostly dominated by the input pair M1-2. The second stage (M5) adds gain for an overall gm of 2.5 mA/V. It is cascoded by M6 to boost its output impedance r_0 from ~80 k Ω to ~400 k Ω without significantly compromising CCO's voltage headroom. With this configuration, the circuit operates correctly with a supply voltage as low as $2V_{GS} + 2V_{DS} \cong 0.8$ V ($2V_{GS}$ for the CCO headroom and $2V_{DS}$ for M5 and M6 in Fig. 5).

The offset of the gm-stage together with the PVT variations of the CCO can create a large spread in the nominal CCO frequency F_{NOM} . An excessively high F_{NOM} can cause counter failure while an excessively low F_{NOM} can both cause excessive quantization noise and force the CCO in a highly non-linear operating region. Moreover, large changes of F_{NOM} over temperature can cause the delay of the VCO to change, and add a temperature-dependent phase error, i.e. more inaccuracy. Therefore, F_{NOM} is trimmed by a 6-bit current DAC (IDAC) before every conversion. During this process, the counter is configured to only count up, while external logic implements a simple ramp algorithm that monitors the counter's 4th LSB (toggling at $F_{VCO}/16$) and increments the IDAC's input until F_{VCO} is ~630 MHz. This whole calibration process takes less than 100 μ s over the specified supply-voltage and temperature range. One LSB of the trimming IDAC corresponds to a 62.5-MHz average step on F_{NOM} , thus resulting in $F_{NOM} = 630$ MHz \pm 62.5 MHz, which is enough to guarantee negligible phase error. The IDAC can compensate an error up to \pm 20 mV referred at the gm-stage input, which is large enough to cover PVT variations as well as amplifier offset.

During phase calibration, the current source for phase calibration (ICAL in Fig. 4) is switched between the two thermopile resistors of the ETF to generate an AC square wave with amplitude up to 2 mVpp at the gm input. Biasing transistor M7 determines the common mode voltage of the ETF thermopiles. ICAL has been designed as a 2-bit current DAC with a unit current of 125

nA, in order to test the effect of front-end non-linearity on the phase-calibration technique. Since this non-linearity was found to be negligible during experimental characterization, ICAL is always operated at its maximum current of 500 nA.

Fig. 6 shows the circuit level implementation of CCO. The gm-stage is modelled as a current source I_{CCO} with impedance source resistance of r_0 . In order to minimize area and maximize CCO gain (K_{CCO}), the CCO is implemented as a ring oscillator with the minimum number of stages, i.e. 3 stages. Each transistor in the inverters is sized with minimum length and twice the minimum width, to ensure that CCO output swing is low enough to ensure voltage headroom at the output of the gm state for sub-1V operation. With these design choices, r_{CCO} is ~30 K Ω at 25 °C and is much smaller than r_0 , as intended.

The impact of the CCO's phase noise on the sensor's resolution is reduced by the gain of the preceding gm-stage. Moreover, only a narrow-band component of this noise around F_{DRIVE} is involved, since the CCO's output is synchronously demodulated. As a result, the noise of the gm-stage is dominant in this design. As explained before, the CCO's PVT variation is corrected by trimming F_{NOM} before every conversion.

Since the CCO's voltage swing is small and depends on PVT, it is boosted to logic-compatible levels by a single-stage differential amplifier (M1-4) referenced to a replica inverter. The amplifier is designed for speed, since its delay adds to the phase shift of the gm-stage. It has a nominal AC gain of 10 dB over a bandwidth of 900 MHz and consumes only 50 μ A. After the amplifier, three tapered inverters provide the strength to drive the 8-bit counter.

The 8-bit up/down counter was synthesized from standard cells and laid out via a standard place-&-route tool. According to simulation, it can operate at a clock frequency up to 1 GHz over all corners, 0.9-1.2V supply voltage and the temperature range. The up/down signal (F_{DEM}) is re-clocked by F_{VCO} to avoid metastability in the counter. The 3-bit sampling register also

employs standard cells and its sampling clock (F_S) is generated by the digital logic and is reclocked by the falling edge of F_{VCO} , which means that the up/down counter must settle within a half period of F_{VCO} .

Fig. 7 shows the schematic of the digital logic that generate the signals driving the ETF heater and the counter, along with the truth table describing the function of the combinational logic. The heater-driving transistor MD controls the current flow in the ETF heater R_{HEAT} to create the ETF heat pulse. To minimize the parasitic series resistance and hence maximize the power efficiency of the ETF, each heater ($R_{HEAT} = 188~\Omega$) is driven by a large NMOS (W=68 μ m, L=40 nm, $R_{on} \sim 20~\Omega$). The large gate capacitance of MD is driven by a digital buffer implemented as tapered inverters. Since any delay mismatch between F_{DRIVE} and F_{DEM} would result in a phase error and, consequently, in additional inaccuracy, the up/down signal path mirrors the drive path by using the same synchronizing flip-flop and digital buffer between the phase DAC output (F_{DAC}) and the counter input (F_{DEM}).

The signals CAL_MODE and TRIM set the system in phase calibration and CCO trimming modes, respectively. When either mode is selected, a relatively high frequency signal ($F_{SYNC}/2$) is provided to the ETF. At this frequency, the ETF's AC output is quite small, while the same self-heating-induced DC offset is present as in normal operation [11]. In addition, when phase calibration is enabled, a delayed version of F_{DRIVE} (generated by an auxiliary output of the phase DAC) is delivered to the gm-stage via F_{CAL} . When TRIM mode is enabled, the counter is forced to count only up and both the ETF input and the F_{CAL} signals are disabled to guarantee that the VCO only sees the offset of the gm-stage and the self-heating of the ETF.

V. EXPERIMENTAL RESULTS

The prototype was realized in a standard 40-nm CMOS process and occupies an active area of 0.23 mm² (Fig. 8). It consists of an array of 12x2 sensors, 12x2 test structures, 2 test heaters

(resistors), a shared bias-current generator and shared digital I/O logic (shift registers and multiplexers for testability). Each sensor occupies $61 \, \mu m \times 27 \, \mu m$, and dissipates $2.5 \, mW$, most of which (88%) is dissipated in the ETF.

In each sensor, the ETF occupies only 15% of the 1650 μm^2 sensor area, while the analog and digital circuitry occupy 25% and 60%, respectively. In 40-nm CMOS, the sensor is about 2x smaller than previous designs in 160-nm CMOS [13], even though it includes many additional features, such as phase calibration, multi-bit feedback and the phase DAC's reference generation. The area required for the decimation filter and the CCO's trimming logic is estimated to be about 600 μm^2 , but since those functions do not necessarily need to be co-located within the sensor, they were implemented off-chip for flexibility. Functionality of each sensor was verified over (digital and analog) supply voltages ranging from 0.9 to 1.2 V (nominal supply is 1.05V), and a 2.8 °C/V supply sensitivity was observed over such range.

The phase vs. temperature characteristics of both ETFs from -40 to 125 °C (averaged over 24 dies and 144 sensors for each ETF) at 1.17-MHz drive frequency were used to generate the 5th-order polynomial master curves shown in Fig. 9. Those master curves were used to convert the decimated output of each PD $\Sigma\Delta M$ into a temperature reading. Over the measured temperature range, the master curves can be well approximated by a T^n power-law [23]. For the 3.3- μ m and 2- μ m ETFs, good fits were obtained with n=0.98 and n=0.95, respectively, which agrees well with previous work [12,24].

Fig. 10 shows the power spectral density (PSD) of the 3-bit digital output of both the 3.3- μ m and 2- μ m ETF's. The thermal noise floor corresponds to a resolution of 0.36 °C (RMS) for the 3.3- μ m ETF and 0.24 °C (RMS) for the 2- μ m ETF, both obtained for a bandwidth of 500 Hz, i.e. at a sampling rate of 1 kSa/s.

The additional phase due to the readout can be detected and removed via phase calibration. Fig. 11 shows the phase error of the readout circuitry of 144 sensors, measured at a reference phase of 22.5° (Fig. 11). The mean phase error is 1.3° and it exhibits a slight curvature over temperature. Phase calibration can be done continuously, e.g. after every conversion, but at the expense of halving the conversion rate and degrading the resolution from 0.24 °C for the 2-μm ETF (0.36 °C for the 3.3-μm ETF) to 0.40 °C (0.5 °C). Alternatively, it can be done one-time at room temperature after fabrication but at the expense of increased inaccuracy.

As shown in Fig. 12, the sensors based on the 3.3- μ m ETF achieve an untrimmed inaccuracy of $\pm 1.8^{\circ}$ C (3 σ , 144 sensors, 24 dies) from -40 to 125 $^{\circ}$ C for a supply voltage of 1.05V. The inaccuracy improves to $\pm 1.4^{\circ}$ C (3 σ) after a one-time phase calibration at room temperature, and to $\pm 0.75^{\circ}$ C (3 σ) after temperature calibration at 25 $^{\circ}$ C. Continuous phase calibration improves inaccuracy to $\pm 0.5^{\circ}$ C (3 σ). At a 0.9-V supply voltage, the digital logic slows down, resulting in an untrimmed inaccuracy of $\pm 2.3^{\circ}$ C (3 σ), and $\pm 1.2^{\circ}$ C (3 σ) after trimming.

The improved resolution of the 2- μ m ETFs comes at the expense of accuracy, as shown in Fig. 12. Their untrimmed inaccuracy is $\pm 2.3^{\circ}$ C (3 σ , 144 sensors, 24 dies) after a one-time or continuous phase calibration. After a single-temperature calibration, those values reduce to $\pm 1.05^{\circ}$ C (3 σ) and $\pm 0.85^{\circ}$ C (3 σ), respectively.

Self-heating of the ETFs (1.7 °C and 4 °C for the 3.3- μ m and 2- μ m ETF, respectively) is estimated to spread by approximately 20% due to the spread in heater resistance and in parasitic resistance of the driving transistor This results in an error of ± 0.35 °C (3 σ) for the 3.3- μ m ETF and ± 0.8 °C (3 σ) for the 2- μ m ETF, which is already included in the ± 1.4 °C (3.3- μ m ETF) and ± 2.3 °C (2- μ m ETF) values reported above.

In order to test the sensor's sensitivity to mechanical stress, 16 dies (each containing 6x 3.3µm ETF and 6x 2-µm ETFs) were packaged in standard SO28 plastic packages. As shown in Fig. 13, the untrimmed inaccuracy of 96, 3.3- μ m ETFs, was ± 2.3 °C (3 σ). Compared to the ceramic-packaged devices, more spread was observed, which may be due to the additional self-heating in plastic packages and to the stress sensitivity of the thermal diffusivity of silicon [25]. After a PTAT trim, the spread drops to ± 0.75 °C (3 σ); which is the same for plastic and ceramic packaged sensors.

To characterize the nonlinearity of the PD $\Sigma\Delta M$, they were exposed to a temperature ramp from -40 to 125 °C. Fig. 14 shows the statistical averages obtained from a 50 mK/sample ramp. It can be seen that no artifacts occur during the measurement.

The sensor's performance with both ETFs is summarized in Table II and compared to that of other sensors intended for thermal-monitoring applications. Due to the amount of power dissipated in the ETF, the proposed sensor is not particularly energy efficient, as can be seen from its relatively poor resolution FoM [28]. However, with the 3.3-µm ETF, the proposed sensor is the most accurate and the smallest, except for a sensor that requires an accurate external voltage reference (which is not included in the reported area) [15]. It also has the second lowest operating supply voltage (0.9 V), which is mainly limited by the up/down counter. Compared to TD sensors implemented in more mature technologies [13], it achieves 1.5x better resolution and 2x more accuracy, while requiring about 2x less area.

VI. CONCLUSIONS

A compact TD sensor in 40-nm CMOS has been described, and techniques which allow the sensor to be implemented in a compact area have been presented. The sensor's area, speed, resolution and power-supply rejection satisfy typical specifications for SoC thermal monitoring, while its untrimmed inaccuracy is the lowest reported for temperature sensors in nanometer CMOS below 40 nm. The performance (area, accuracy, power, speed) of TD sensors has been demonstrated to improve with process scaling, and additional improvements can be reasonably expected in future more advanced technologies. These results demonstrate that TD-based

temperature sensors are suitable for hot-spot monitoring in microprocessors and other systemson-chip.

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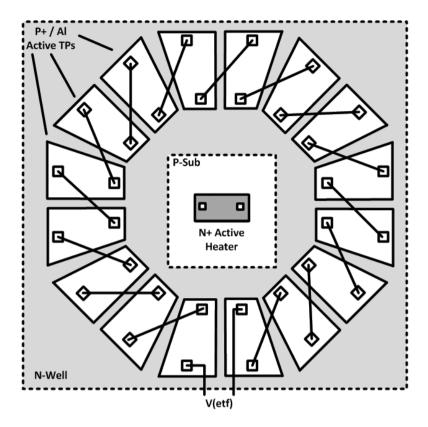


Fig. 1. Simplified layout of the proposed octagonal ETF in standard CMOS.

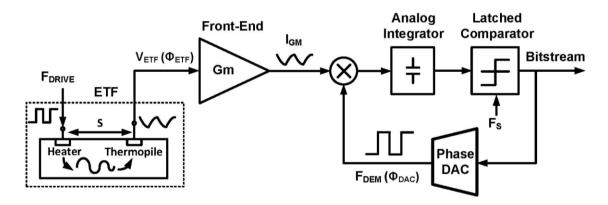


Fig. 2. Simple block diagram of a phase-domain $\Sigma\Delta$ digitizing the phase output of an ETF.

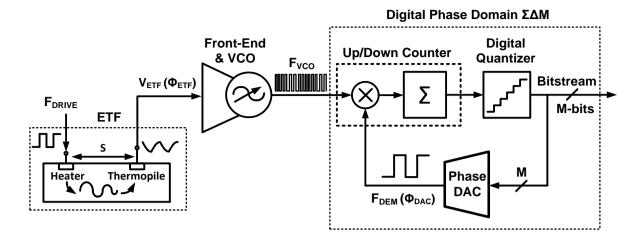


Fig. 3. Block diagram of a VCO-based phase-domain $\Sigma\Delta$.

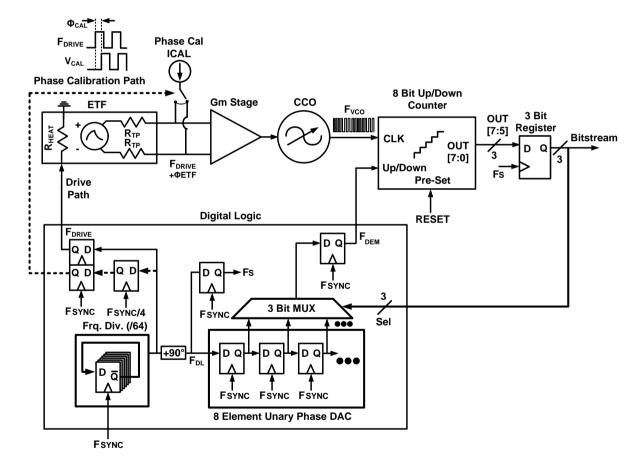


Fig. 4. Block diagram of the 3-bit VCO-based phase phase domain $\Sigma\Delta$ modulator with phase calibration.

TABLE I. NOISE, DELAY AND POWER BUDGETING BETWEEN ETF AND READOUT BLOCKS

Circuit Block	Thermal Noise Density (Voltage)	Noise Density* (Phase)	Power**	Phase Delay (F _{DRIVE} = 1.17 MHz)	
ETF ($s = 2 \mu m$)	13.7 nV/√Hz	1.01 m°/√Hz	2.1 mW	0.6°	
ETF ($s = 3.3 \mu m$)	11.4 nV/√Hz	1.54 m°/√Hz	2.1 mW	0.4°	
Gm-Stage + CCO (s = 2 μm)	10 nV/√Hz	0.73 m°/√Hz	0.17 mW	0.75°	
Gm-Stage + CCO (s = 3.3 μm)	TO HV/VHZ	1.35 m°/√Hz	0.17 mw		
Up/Down Counter	-	-	0.26 mW	-	
Phase DAC	-	-	0.01 mW	0.1°	
Total (s = 2 μm)	17 nV/√Hz	1.24 m°/√Hz	2.5 mW	1.45°	
Total (s = 3.3 μm)	Total (s = 3.3 μm) 15.2 nV/\sqrt{Hz}		2.5 mW	1.25°	

^{* 1.3-}mVpp ETF signal assumed for voltage to phase noise conversion for $s=3.3~\mu m$ * 2.4-mVpp ETF signal assumed for voltage to phase noise conversion for $s=2~\mu m$

^{**} $V_{DD} = 1.05 \text{ V}$

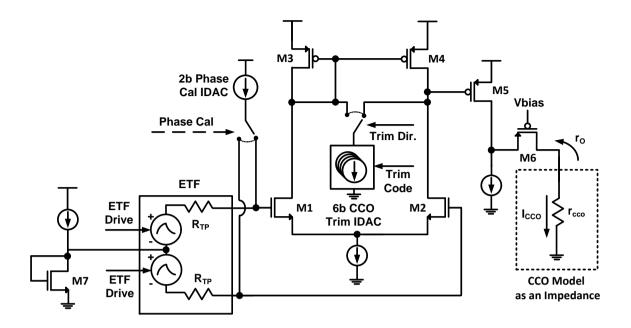


Fig. 5. Circuit diagram of the Gm-stage (cascaded CCO modelled as resisitve load r_{CCO})

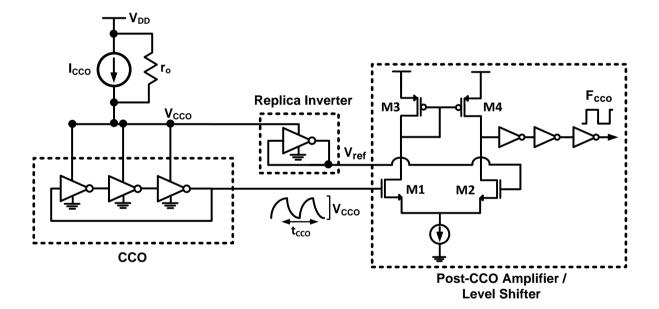
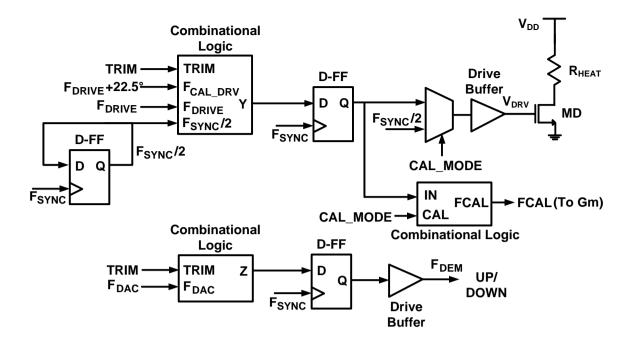


Fig. 6. Circuit diagram of the CCO and the cascaded level shifter amplifier. The driving gm stage is modelled with its Norton equivalent (I_{CCO} current source and r_O output impedance).



TRIM	CAL_MODE	Y	Z	FCAL	VDRV
0	0	F _{DRIVE}	F _{DAC}	0	F _{DRIVE}
0	1	F _{CAL_DRV}	F _{DAC}	F _{CAL_DRV}	F _{SYNC} /2
1	X	F _{SYNC} /2	0	0	F _{SYNC} /2

Fig. 7. Block diagram of the sensor digital logic for generation of F_{DRV} and F_{DEM} and truth table that describes the combinational logic function.

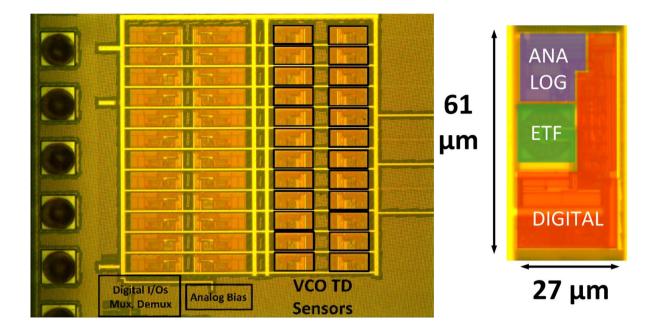


Fig. 8. Die photo, along with a zoomed-in photo of a single temperature sensor. The sensor's photo is showing the breakdown of area occupied by the ETF and circuitry.

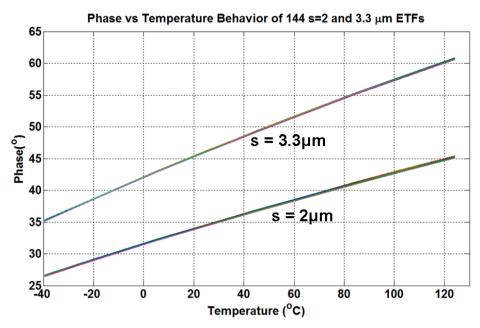


Fig. 9. Measured phase of $s=2\mu m$ and $s=3.3\mu m$ ETFs over temperature ($F_{DRIVE}=1.17MHz,\ 144\ samples$)

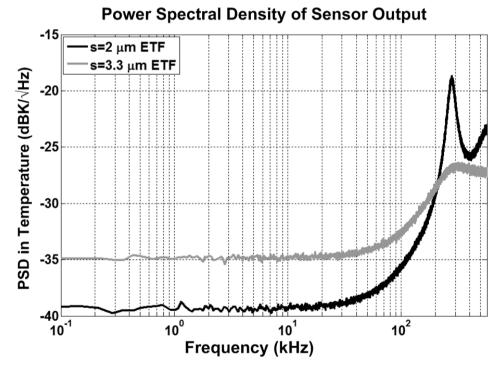


Fig. 10. PSD of the sensor's bitstream (8 million points, Fs = 1.17MHz)

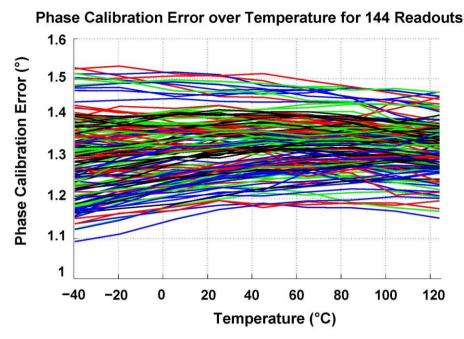


Fig. 11. Measured phase error of the readout circuitry of 144 sensors from -40 to 125 °C.

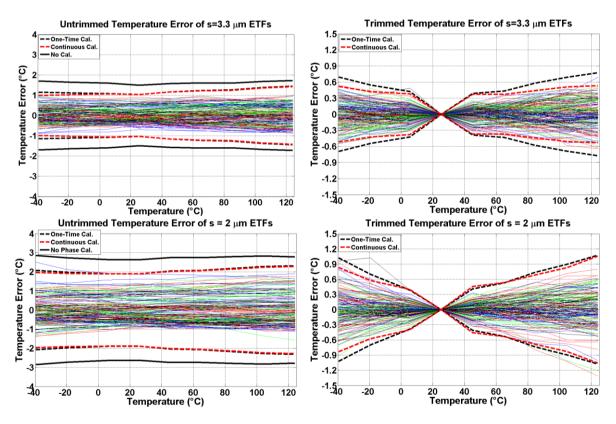


Fig. 12. Untrimmed and single-point trim inaccuracy for 144 sensors with s=3.3 μ m (top plots) and s=2 μ m (bottom plots). Individual lines represent the inaccuracy of each sensor with one-time phase cal., while the bold lines indicate the 3 σ limits for no phase cal., one-time phase cal. at 25 °C, and the red dashed lines represent continuous phase cal.

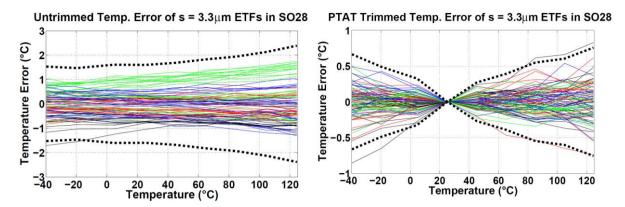
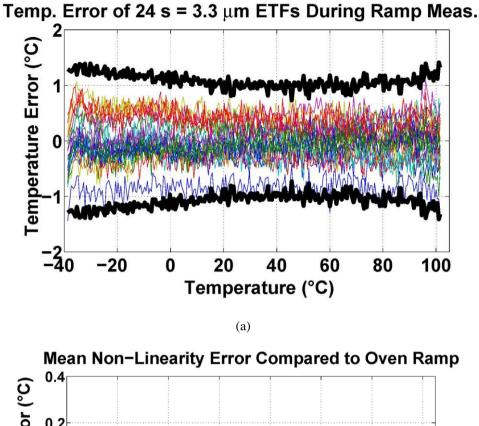


Fig. 13. Untrimmed and gain or PTAT trimmed inaccuracy for 96 sensors with s=3.3 μ m, in 16 SO28 plastic packages. Individual lines represent the inaccuracy of each sensor with one-time phase cal., while the dashed lines indicate the 3 σ limits for one-time phase cal. at 25 °C.



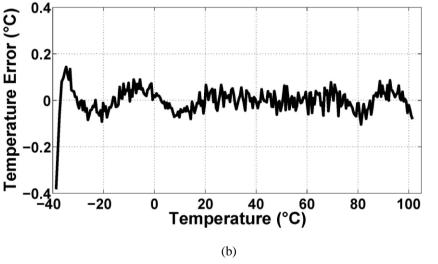


Fig. 14. (a) Temperature error of 24 sensors with 3.3- μ m ETFs during a ramped temperature test (50 mK/sample temperature slope, 1 kSa/s sample rate). Bold lines indicate 3σ limits. (b) Non-linearity error between oven ramp and mean sensor output over temperature.

PERFORMANCE SUMMARY AND COMPARISON TABLE II.

	This V	Vork	[13]	[15]	[5]	[4]	[26]	[27]	[14]
Technology	40nm		160nm	32nm	14nm	32nm	16nm	28nm	65nm
Sensor Type	TD (3.3µm)	TD (2µm)	TD (3.3µm)	Diode	BJT	BJT	BJT	BJT	MOS
Inaccuracy No Temp Cal. (3σ, °C)	±1.4	±2.3	±2.9	=	±4.7	±5	±2.0	±1.8	•
Single Temp. Cal. (3σ, °C)	±0.75	±1.05	±1.2	-	±2.3	-	-	-	
Two Temp. Cal. (3σ, °C)	-	•	-	±2.6	±0.7	-	-	•	±0.9*
Temp. Range (°C)	-40 to 125	-40 to 125	-35 to 125	0 to 100	0 to 100	-10 to 110	-50 to 150	-20 to 130	0 to 100
Area (µm²)	1650		2800***	1000**	8700	20000	12600	3800	4000
Resolution (°C, RMS)	0.36	0.24	0.47	0.25	0.5	0.15	0.38	0.58	0.3
Speed (kSa/s)	1		1	2.5	50	1.2	3.66	250	45
Supply Voltage (V)	0.9 – 1.2		1.8	1.65	1.35	1.05	-	1.1 - 1.8	0.85-1.05
Power (mW)	2.5		2.4	0.1	1.1	1.6	1.21	0.016	0.15
Resolution FoM (nJ·K²)****	324	144	530	2.5	5.5	30	47	0.021	0.3

^{*} Peak to peak error variation (7 samples)
** Area of precision voltage reference not included

^{****} Shared phase DAC area (~600 µm²) not included
***** Resolution figure of merit (FoM) is defined as Power*Conversion Time*Resolution²

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